# Standard Operating Procedure I PHI 5000 VersaProbe II XPS/UPS (Basic XPS Measurement)



Yale West Campus Materials Characterization Core *ywcmatsci.yale.edu*  ESC II, Room E119E 810 West Campus Drive West Haven, CT 06516

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- Please FOLLOW the SOP strictly to keep the facility in good condition.
   Any explorations are strongly prohibited unless permitted by lab manager
- > **NEVER** use your own USB drive on the XPS computer. Data can be either uploaded to Yale Box, or copied to the Jump Drive provided by the Core.
- > **NEVER** surf the web on the XPS computer to minimize the risk of the computer being hacked
- > Yale West Campus MCC users should acknowledge MCC in their publications. Please check the following link for details: http://ywcmatsci.yale.edu/publications
- > The core reserves the right to use the data for core promotion

### Table of Contents

1		Inti	roduction1
2		Sys	stem Initial Status Check
3		Sar	nple Preparation
	3.	1	Sample holders
	3.2	2	Sample Mounting
4		Act	tivate FOM Program
5		Cre	eate Sample in SmartSoft Program
6		Sar	nple Loading into Intro Chamber
7		Sar	nple Transfer into Main Chamber
8		XP	S Scan
	8.	1	Initial analysis position definition and Z-Alignment
	8.2	2	Create multiple positions on samples
	8.	3	XPS Survey (Full Range) Scan
	8.4	4	Regional (Elemental) Scan
9		Clo	osing XPS Measurement
1(	)	Soi	me Analysis Concepts
1	1	Va	cuum Loss Emergency Operation Procedure

### PHI 5000 VersaProbe II XPS/UP S Standard Operating Procedure (Basic XPS Measurement)

#### 1 Introduction

#### 1) Features of this Instrument:

- > Micro-area element composition and chemical state determination on material surfaces
- > Analysis of insulating samples with dual beam charge neutralization method
- > Depth profile analysis of structures and interfaces

#### 2) Location

Materials Characterization Core Room E119 810 West Campus Dr West Haven, CT 06516

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The Yale West Campus MCC Facilities are operated for the benefit of all researchers. If you encounter any problems with this facility, please contact the staff member listed above immediately. There is never a penalty for asking questions. If the equipment is not behaving exactly the way it should, contact a staff member.

**Notice**: Please **follow** strictly the **SOP** to keep the facility under good condition. We **DO NOT** recommend user explorations on program unless endorsed by core staff.

#### 2 System Initial Status Check

**Notice**: Before sample preparation and loading, the users are required to check the XPS system status following the steps listed below:

1) Check to see if the XPS instrument is **ON**, i.e., the **green light** highlighted by an arrow on the right side control rank is illuminated and there are pressure displays on the vacuum gauge reading:

Warning: If you find that the XPS instrument is **OFF**, contact a MCC staff member for help.



- 2) Check if the XPS computer is **ON**. Start the computer if it is **OFF**.
- Check the pressure reading of the Main Chamber Ion Gauge on the XPS control rack: It should be in the range of low 10<sup>-7</sup> Pa or high 10<sup>-8</sup> Pa when the system is idle. Warning: If the pressure reading is above 8×10<sup>-6</sup> Pa, contact a MCC staff member for help.



4) Sign in on the logbook and put down date, usage time, sample materials, Main Chamber and Intro Chamber initial pressure before sample loading, data collection modes used, and report any issues during measurement.

#### 3 Sample Preparation

#### Warnings:

- > Always wear lab coat and gloves for vacuum sample preparation!
- > The sample for XPS and UPS needs to be **completely dried!** If the pumping time in intro chamber exceeds 1 hour, the sample must be taken out for further treatment.
- 3.1 Sample holders
  - 1) **1 inch** regular sample holder for **as-is** sample analysis. This is most used sample holder which can hold more **15** samples (3 x 3 mm<sup>2</sup>)



2) 60 mm large sample holder for as-is sample analysis. This holder is very useful to hold large samples and large number of small samples.



Angle Resolved (AR) XPS/UPS using AR sample holder.
 Note: users should choose AR holder for UPS measurements



 4) 1 inch Heating Sample Holder with heater if *in situ* heating is required Temperature range: RT – 800 °C



**Rectangle Heater** 



Thermocouple

#### Warning:

- > Use the **rectangle mask** only with **flat cross head** screws.
- > Choose the right size cross screwdriver for sample mounting. The screws can be easily damaged with wrong size screwdrivers. Users are not allowed to fix sample holder, report to lab staff immediately.

- > Choose the right type of holder in **HC Control** program and keep **Reading** Heater Power below 75%. Violation will lead to damage to the stage and sample holder. User's account will be suspended and repair cost will be charged on PI's account.
- 5) 1 inch Heating/Cooling Sample Holder if *in situ* cooling and heating required Temperature range: -140 °C – 600 °C



**Rectangle Heater** 

Thermocouple

3.2 Sample Mounting

Warning: the maximum sample thickness is 5 mm above sample holder top surface



Notice: The minimal sample size should be 3 mm x 3 mm for XPS and 5 mm x 5 mm for **UPS** (UV beam size at stage is  $\sim 4 \text{ mm x } 4 \text{ mm}$ ).

- 1) Non-powder samples:
  - a) Fix sample with copper clips or Mo cover on the sample holder (the sample can be heated in vacuum):
  - b) Fix sample using **double sided Scotch tape** (for **XPS** only) (for **XPS/UPS**). (sample cannot be heated in vacuum)

Warning: after sample mounting, shake and tilt sample holder to make sure no loose sample or particles on the holder.

- 2) Powder Samples:
  - a) Choose **Si wafer** as support (the sample can be **heated** in vacuum):
    - > Add powder in solvents such as ethanol, isopropanol (IPA) or Dichloromethane (DCM) and mix the solution using ultrasonicator.
    - > Drip small amount of suspension onto a piece of Si wafer  $(3x3 \text{ mm}^2 \sim 5x5)$  $mm^2$ )
    - > **Dry** sample about 10 minutes under infrared lamp
    - > Repeat above steps to have enough deposition on Si substrate

- > **Mount** sample on the holder using copper clips or Mo cover if heating is needed in vacuum;
- b) Choose double sided tapes (sample cannot be heated in vacuum)
  - Sprinkle powder on Scotch tapes (XPS only) or carbon conductive tapes (XPS/UPS), then cover the surface with weighing paper and firmly press the surface with spatula

Warning: carefully remove all loose particles from the sample holder:

- > **Shake** and tilt down the sample holder to make sure no additional particles comes loose
- > **Blow** the sample surface with dry  $N_2$  inside fume hood

#### 4 Activate FOM Program

> In the FOM Scree Lock window, click on **Click here to login with NetID** to unlock the screen.

Click here to login with NetID	
Or Click here if you do not have a NetID	

#### 5 Create Sample in SmartSoft Program

**Notice: "Create Sample"** is the first step of data analysis. **It must be done before taking picture of the sample in Intro Chamber.** The following steps should be taken to create sample (platen):

1) Open **SmartSoft-VersaProbe** program on desktop (if the program was closed) and click **OK** (no password required).

2) Click System to enter the System window, then click the Sample Transfer on the right side to enter Sample Transfer tab.

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Create Sample	Sa
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Transfer Sample	ansf
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Advanced Control	<u>୍</u> ଲ
Properties	Imera

3) Click Create Sample... button to open Create Platen (sample) window

**Warning**: once a **New Platen Name** is created, **NEVER** change or **CREATE** a new platen name once the data collection has started. **Violations may lead to hardware damages** inside vacuum as all sampling positions are affiliated with the initial Platen Name.

	- • •
K-2	-
ОК	Cancel
	<₽ OK

4) Create a new platen name and hit OK, the Data Manager Properties window appears. Make sure sample holder of 25 mm is chosen if the 1 inch regular sample holder is used. Note: choose the corresponding sample holder if Angle Resolved (AR) or 60 mm sample holders is used.

Data Manager Prop	perties
Platen	Lab Book Directory Contact Info.
Platen	
	Name CFx-21
	Type 25 mm
Image	Overlav El
May	7 Height 18 50
	TO.30
Sample L	ocation Intro

5) Click **Directory** and specify the data **Acquisition Directory** 

Data Manager Pro	perties		×				
Platen	Lab Book	Directory	Contact Info.				
-Acquisition D	Acquisition Directory						
C:\Datafiles\							
'Auto' Directo	'Auto' Directory						
🗖 Use	'Auto' Directory		0				

- 6) Hit **OK** and **Close** above window.
- 6 Sample Loading into Intro Chamber
  - The sample holder with either solid or powder sample must be blown with nitrogen gas to make sure NO loose particles, hair or fibers on the holder.
  - 2) Check the system status before sample loading:
    - a) At the bottom right of the **SmartSoft** program window, check to **confirm** X-ray source is **OFF** KRay. Off, Electron Neutralizer **OFF** ENeut. Off [A] and Ion gun **OFF**

IGun: Off [A]. Contact Core manager immediately if not.

b) In system diagram below, check if "V1" valve is **closed** (in **red** border) between **Intro** and **Main Chambers**. If not, **contact** lab manager immediately.



c) Turn **ON** the Main Chamber light.



- d) Confirm no sample holder inside Main Chamber:
  - > Look through the **view port** to confirm no samples in the **Main Chamber**,
  - > Check the system diagram in SmartSoft window above and make sure that the blank square box is shown in on the stage in Main Chamber. Report to lab manager immediately if not.

**Note**: User should remove and clean the previous sample holder left in the **Intro Chamber**. User can leave the sample inside the intro chamber after finish, which will be discarded by next user.

e) Check building supply N<sub>2</sub> pressure on the wall behind computer monitor and make sure it is set below ~ 3 psi. If the pressure is above 3 psi, decrease the pressure setting to 3 psi by turning the pressure regulator valve *counterclockwise*. Contact MCC staff if assistance needed.



3) In the system diagram in Step 2), check if Intro Chamber in vacuum, then click in the Sample Transfer window below:

Warning: the user must wear gloves at hold the glass cover during venting.

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CON Pump € Vent Vent Vent	e"
🗣 Intro 🦻 Extract	
Advanced Control	<b>0</b>
Properties	mera

4) Wear gloves, wait until the Intro Chamber is vented, remove the Viton cover and slide the nitrogen cleaned sample holder along the round dent on the bottom of the sample holder onto the transfer arm fork

#### Warning:

- > User CAN NOT touch the sample loading port with exposed skins
- > **DO NOT** touch the camera atop the loading port
- > The sample holder must have been cleaned with nitrogen gas

5) Make sure the dent on sample holder aligns with and touch the screw on the transfer arm fork and check from side window flange if the holder stays flat on the fork: Warning: Users should follow STRICTLY the steps below to avoid transfer failure and parts damage.



6) Leave the loading port **open**, **fully retract** the transfer arm so that the **bullet** on magnet **touches** the stopper ring on the transfer arm



7) In the **SmartSoft** program System window, click button on the **Transfer Sample** window to take a picture of the sample holder:

Sample Transfer	Sa
Create Sample	mple Tr
Transfer Sample	ans
	fer
🗣 Intro 🦻 Extract	
Advanced Control	0
Properties	amera

8) Wait for several seconds for picture loading into **SmartSoft**, click the Sample tab next

to System to enter the Sample window. Check the sample holder photo and make sure the blue circle aligns well with the bottom half of the sample holder. If not, contact lab manager.



9) Check carefully the sealing surface of the Viton cover and the groove on the transfer port/flange; clean using Kimwipes with isopropanol if dusts/particles can be seen; then put the cover back onto the transfer port of the Intro Chamber



10) Click Sample Transfer window and go back to Intro Chamber quickly; hold and press the Viton cover into the flange groove during initial Intro Chamber pumping!

Warning: fail to follow above steps will cause the Intro Chamber leaking during pumping.

**Note: slight rotating** while **pressing** the **Viton cover** before pumping (before sucking air sound) may help to assure the **Viton cover** placed correctly on the flange.

Advanced Control

Properties...

Sample Transfe	er		
Create Sample			San
	😂 Create	Sample	nple T
Transfer Samp		Pump Sent	ransfer
<u></u>	ntro	穿 Extract	

- 11) Check Intro Chamber status right after pumping (after hearing sucking air sound)
  - a) Click System to enter the System window and monitor the Intro Chamber pressure:
    - > The pressure reading from Stage 1 pressure gauge (Pirani gauge) should drop from atmosphere pressure to ~3.0E+001 Pa in ~5 minutes;

Camera

Then, the reading from **Stage 2 pressure gauge** (Cold Cathode gauge) > takes over and should drop from ~ 1E-002 Pa to 4.0E-004 Pa before sample transfer to Main Chamber typically in ~15 minutes;



#### Warning:

- The actual Intro Chamber pumping time will vary on different samples >
- It is strongly recommended to make sure user samples are **DRY and UHV** > (Ultra High Vacuum) compatible. If pumping time exceeds 60 minutes to reach 4.0E-004 Pa, the user must remove the samples from Intro **Chamber** for further treatment.

#### 7 Sample Transfer into Main Chamber

Warning: Users should follow **STRICTLY** the steps below to avoid transfer failure and parts damage.

- Before sample transfer to Main Chamber, the Intro Chamber pressure from Cold Cathode gauge MUST reach below 4.0E-004 Pa Warning:
  - > Sample transfer at high Intro Chamber pressure will introduce serious contaminations to Electron Energy Analyzer, X-ray, UV sources and sample stage.
- 2) Make sure that the **Main Chamber** light is turned **ON**.



3) Click in the Transfer Sample window to start sample transfer from Intro Chamber to Main Chamber

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Create Sample	Sar
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Transfer Sample	ans
Pump Vent	ër
Se Intro	
-Advanced Control	0
Properties	Imera

#### Warning:

- > NEVER stop the transfer process in the middle and force to close the SmartSoft program in Task Manager. Contact Core manager immediately if did by accident
- > MAKE SURE that magnet TOUCHES the stopper ring on the transfer rod
- 4) Wait for the following **window** to appear:



5) Follow the command in above window to move the transfer arm forward and MAKE SURE the magnet TOUCHES the stopper ring and the stopper ring on the transfer arm



Warnings:

- > User should slow down when approaching transfer position. The sample holder should be SMOOTHLY inserted into the sample stage in Main Chamber. CONTACT lab manager immediately if strong force felt at this step,
- > **Slight adjustment** maybe needed to insert sample holder into the stage forks. The user should **CONTACT** lab manager for help,
- NEVER force the sample into sample stage. Expensive parts inside will be damaged. User account will be suspended and repair cost will be charged on PI's account.
- 6) **Leave** the transfer arm at the **transfer position**; **go back to the computer** and click **OK** on the popup window

Warning:

- > NEVER click OK on the window before moving transfer arm forward. Or serious mechanical damage to both stage and sample holder will occur. User account will be suspended and repair cost will be charged on PI's account.
- 7) Wait the following window to appear. DO NOT click OK

Task Infor	mation			<b>—</b>
•	Please	retract transfer arm.	)	
		ОК	Cancel	

#### Warning:

- Failed to follow above step will lead to serious part damage to both sample stage and sample holder. User account will be suspended and repair cost will be charged on PI's account.
- 8) Follows the command in above window to fully retract the transfer arm back to the Intro Chamber

#### Warning:

- > Retract the transfer arm VERY SLOWLY and watch the sample holder through Main Chamber view port. The sample holder should NOT move during transfer arm retraction.
- 9) Go back to the computer and click OK on above window
- 10) Wait until the stage is driven to the center.



- 11) Watch closely the Main Chamber pressure change
  - a) The pressure should drop continuously from low E-006 Pa to E-007 Pa range in a short time, 5 ~ 30 mins depending on samples
     Warning:
    - > To prevent sample **contamination** to Main Chamber:
      - > If the pressure rises quickly/slowly above 5E-006 Pa, remove the samples from Main Chamber immediately

- > If the pressure stays unchanged at low E-006 Pa for more than 30 mins also remove the samples from Main Chamber.
- b) Wait until the pressure reaches **5E-007 Pa** before proceeding to **XPS Scan**. **Warning**:
  - > To prevent sample **contamination** to Main Chamber:
    - > If the pressure drops very slowly and takes more than 60 mins to reach 5E-007 Pa, consider taking the samples out for further treatment.

#### 8 XPS Scan

- 8.1 Initial analysis position definition and Z-Alignment
  - 1) Wait until the Main Chamber pressure reaches 5E-007 Pa
  - 2) Define **initial** analysis **Position** with the sample in **Main Chamber** 
    - > Click Sample on top tab menu to enter Sample window
    - > **Hover** mouse cursor over the sample photo window on the left, **scroll** mouse wheel to enlarge photo and find the sample to be analyzed



- > Right click mouse on intended analysis position and select Drive To Click on the dropdown menu, the Main Chamber Stage will move to the selected position
- > Right click mouse on blue cross cursor select Create Point at Stage on the dropdown menu, an Active Position (ID: 1) will be created in the Position List Table below sample photo window



> Select Position Type as Point in above table for regular point X-ray sources: 100 u25W15kV and 200u50W15kV in XPS window Source Setting in Step 4 **Note**: Select Position Type as **HP** (High Power) in above table if the High Power X-ray source, **100u100W20kV\_HP** is chosen in XPS window Source Setting in **Session 7.3** 

- 3) Sample Z-Alignment
  - > Click **Stage** tab on the right side of **Sample** window to enter **Stage Parameters** window
    - > Input 12 in Z(mm) space and hit Enter on keyboard
    - > Hit \_\_\_\_\_ button on the right side of input number (12.000) and wait for the sample stage to move to entered height (12.000 mm)

Dri	ve Mode:	Absolute	C Relative		
I	arget	<u>Drive</u>	<u>Current</u>		ĺ
X (mm)	-0.892	×	-0.892	Pos	
Y (mm)	1.213	Y	1.213	ltion Li	
Z (mm)	5.006	Z	5.006	रा	
R (deg)	-0.05	R	-0.05		
		Comp R			
T (deg)	45.01	Т	45.01	Sta	
		Eucentric		aĝe	
D	rive All		Stop		

<b>口</b> [1] ゆ	🔩 🐄 🖢 🖌 📔 🕼 1300.0 💌 Total	Z Z C

- > The following windows will pop up sequentially, wait until all windows disappear Note:
  - > The Z-Align optimizes the sample stage height at the maximal photoelectron counts, so X-ray Source, ENEUT (electron neutralizer) and IGun (Ion gun) will be turned ON during Z-Align.

#### Warning:

>Once Z-Align starts, the Intro Chamber pumping will be stopped. user needs to pump the Intro Chamber back to 4.0E-004 Pa before sample transfer back to Intro Chamber

🚺 AutoTool: Z ALIGN			
Ion Neutralization Standby			
	l Stop		
👰 AutoTool: Z ALIGN		AutoTool: Z ALIGN	x
Turning E-Neut On		on Neutralization On	
	Stop	Stop	
Filament Startup	X	🖉 AutoTool: Z ALIGN	×
Emission Current (mA): 1.30	Stop	Optimizing Z Height: SXI	
Click Warning: t of aligned Z	above <b>Position List Ta</b> his step is <b>critical</b> , or the <b>best of the step</b> at <b>~ 17 mm</b> de	<b>able</b> to <b>Update Position</b> after <b>Z-Align</b> the sample will stay at ~ 5 mm <b>Z height</b> inst epending on sample <b>thickness</b>	ead
Warning:	<u> </u>		
> <mark>Rep</mark>	<mark>ort lab manager</mark> imp	mediately if <b>Z-Align</b> fails. This may due	to to
hard	ware failure or program	m bugs.	
. не н н н ю 🕫 💥 🚯			
ve ID Name Com	nent	Type U V Z 🟲 Rotation Tilt	

#### 8.2 Create multiple positions on samples

V

Cu sample#1

- 1) After Z-Align, Right Click on the interested areas on the Sample Photo and select Create Point on the dropdown list.
- 2) Name the positions and choose collection **Type** as either **Point** or **HP** for spectral analysis. Note:

- > If Point is chosen, typically the X-ray source of either 100 u25W15kV or 200u50W15kV should be chosen in XPS window Source Setting in Session 7.3
- > If HP is chosen, the X-ray source of 100u100W20kV\_HP must be chosen in XPS window Source Setting in Session 7.3

#### 8.3 XPS Survey (Full Range) Scan

- 1) Click Less tab on top tab menu to enter **XPS** analysis window and click **Spectrum** tab on the right side:
  - a) In **Source** window, choose **FXS** (Focused X-ray Source)
  - b) In Source Setting window choose typically 200u50W15kV (X-ray beam size: 200 μm, power: 50 W, and e-beam energy: 15 kV)

#### Note:

- > Typically choose 200u50W15kV or smaller power X-ray beam 100u25W15kV if X-ray induced surface damage is a concern; choose Point as Position Type in the sample Position List
- > Choose 100u100W20kV\_HP to improve the signal/noise ration; choose HP as Position Type in the sample Position List
- > DO NOT choose smaller power starting with smaller beam size of 50um or less which are for X-ray imaging or micro analysis only. The spectral Signal/Noise is very low with small X-ray power even after hours of scans.

Spectrum									
	🕂 Spe	<mark>⊿</mark> ₊ More	Add Q						
Source FXS									
⊂Source Setting ≻	Source Setting X-Ray Setting 200u50W15KV								

2) Click on top left of **Regions** window to enlarge the **XPS Regions** (Spectrum) window:

🔯 XPS Regions (Spectrum)											
Active Name Swe	ep Pass	Lower	Range	Upper	eV Step	Ratio	P/N	Analysis Lower	Analysis Ur		
3) Click in above window to erase previous setup parameters											

4) Click on button on the XPS Regions window to open the Periodic Table, and click
 Su to start a Spectral Survey (Su) Scan.

👲 Periodic Table		
Peak ID	Acquisition Setup	Peak ID Filter
Acquisition Setup H Su 2 3	4 5 6 7 8	He B C N O E No

- 5) In **XPS Regions** window:
  - a) Click Pass to change **Pass Energy** to typically **187.850** eV;
  - b) Change eV Step to typically 0.8000 eV;
  - c) Choose Sweep to typically 5 times;
  - d) Close the enlarged XPS Regions window.

#### Notice:

> For Survey scan, typically highest Pass Energy should be chosen to increase signal sensitivity and larger Step size for a quick scan.

💽 XPS Regions (Spectrum)											
Active 🔽	Name Su1s	Sweep 1	Pass 187.850 ▼	Lower 0.0	Range 1100.0	Upper 1100.0	eV Step 0.8000 ▼	Ratio 1	P/N 1	Analysis Lower 0.0	Analysis Up 1100.0

### XPS Setup...

- 6) Click on button on the bottom of the **Spectrum** window:
  - a) Make sure **XPS: E-NEUT Neutralization** is checked on **Auto** [A]
  - b) Make sure XPS: Ion Gun Neut is checked on Auto [A]
  - c) For Survey scan only, check Auto [A] in XPS: Z-Align
  - d) Make sure **Presputter** is **Disabled**
  - e) Make sure Auto Beam Parking is Disabled
  - f) Make sure Acceptance Angle is Standard
  - g) Hit Close to quit XPS Acquisition Setup

XPS Acquisition Setup
Setup Region
-Automated Neutralization
XPS: E-Neut Neutralization ⓒ Auto [A] 〇 Off
E-Neut Setting E-Neut
Source Tolerance Required C Enabled
XPS: Ion Gun Neut 💿 Auto [A] 🕓 Off
Ion Gun Setting
Acquisiton: Ion Gun Neut Per Position
Z-Align: Ion Gun Neut Continuous
Automated Z-Align Before Acquire
XPS: Z-Align <ul> <li>Auto [A]</li> <li>Off</li> </ul>
X-Ray Setting 100u25W15KV
X-Ray Setting (High Power) 100u100W20KV_HP
Presputter Before Acquire
Presputter C Enabled 📀 Disabled
Gun Type Ar 🗾
Presputter Setting 4KV3x3
Zalar C Enabled 💿 Disabled
Presputter Time (min) 2.00 0 A
Beam Parking
Auto Beam Parking C Enabled
X-Ray Setting 9u1.0W15KV
Auto Shutdown C Enabled 📀 Disabled
Auto Shutdown Delay (hrs) 1.0
Acceptance Angle
Acceptance Angle  Standard Narrow
Close

7) Hit <sup>+\*</sup> Spe in Spectrum window to start Survey scan



8) Wait until the following windows to appear:

😡 AutoTool: ACQUIRE SPECTRUM-1	Acquisition Status
	XPS Spectral Acquire: 14 (sec)
Acquiring Spectrum	Areas: 1/1 Cycles: 1/1 Regions: 1/1 Sweeps: 1/1
	Stop Abort

9) The Survey spectrum will appear in the **Spectral Window**.

Note:

- > The data **filename** starts with Platen Name "Standard samples", the serial number "103", spectra scan extension "**spe**", and scan type Survey "**Su1s**".
- > The data files have been automatically saved into specified folder which can also be opened in **MultiPak** program



### 8.4 Regional (Elemental) Scan

## 1) Click on the Survey spectrum just collected to start Peak ID



2) Click on top left corner of **Regions** window to Show Table Details of the **XPS Regions (Spectrum)** window, and click to open **Import Elements** window

👲 XPS Re	egions (Spe	ctrum)	1								. • 💌
+ #	- ^	v Ø									
Active	Name	Sweep	Pass	Lower	Range	Upper	e∨ Step	Ratio	P/N	Analysis Lower	Analysis Ur
		_									
		Im	port Elements					×			
			Impor	Element	s						
			Import Elem	ents From	n						
				I	mport Spe	ectrum					
					Import D	enth					
					mporte	000					
					Import A	ngle					
					Import L	.ine					
					Import N	/ap					
						/		_			
				Imp	ort Spectra	al Display					
							Clo	ose			
							<u> </u>				

- 3) Click Import Spectral Display button in the Import Elements window above and hit Close.
- 4) The elements detected in Survey Scan are imported into the XPS Regions table as below.

💿 XP:	🔯 XPS Regions (Spectrum)												
+													
Activ	e Name	Sweep	Pass	Lower	Range	Upper	eV Step	Ratio	P/N	Analysis Lower	Analysis Upper		
	C1s	1	23.500 👻	278.0	20.0	298.0	0.0500 👻	6	1	279.0	297.0		
<b>I</b>	O1s	1	23.500 -	523.0	20.0	543.0	0.0500 -	6	1	524.0	542.0		
	Cu2p3		23.500 -	927.0	25.0	952.0	0.0500 -	6	1	928.0	951.0		

- > Click space below Sweep to change Number of Sweeps to typically 5 ~ 20 depending on peak intensity collected in Survey spectra, Note:
  - > Consider choose HP source if samples are not sensitive to X-ray radiation. The signal will be doubled comparing to 200u50W15kV source,
  - > Remember to change the Position Type to HP in the Sample Position List in Sample window if HP source is chosen.
- > Click space below Pass to change Pass Energy to typically 23.500 eV,
- > Click space below eV Step to change Step Size to typically 0.1000 eV,
- > Close the XPS Regions (Spectrum) window. Note:

For Region scan, typically smaller Pass Energy (23.5 – 58.7 eV), smaller Step size (0.05 – 0.25 eV), and 20 ms Time Per Step should be chosen to increase spectral energy resolution.

#### Warnings:

- > Always keep in mind that both Signal Sensitivity and Energy Resolution should be considered for Region Scan.
- > Set Pass Energy too small (< 23.5 eV) will only lower X-ray intensity/sensitivity and make spectrum noisy;
- > Set **Step** size **too small** (<**0.05 eV**) will **only increase scan time** without too much improvement in spectral resolution.

#### XPS Setup...

- 5) Click on \_\_\_\_\_\_ button on the bottom of the **Spectrum** window:
  - a) Make sure **XPS: E-NEUT Neutralization** is checked on **Auto** [A]
  - b) Make sure **XPS: Ion Gun Neut** is checked on **Auto** [A]
  - c) Uncheck Auto [A] in XPS: Z-Align
- 6) Hit <sup># Spe</sup> in Spectrum window to start Region scan

Spectrum	1		
	+ Spe	<mark>ہ</mark> More	Add Q
Source			
	Source F	FXS	•
-Source Setting			
>	K-Ray Setting	200u50W15KV	•

#### 7) Wait until the following windows to appear

👰 AutoTool: ACQUIRE SPECTRUM-1 📃 📼	Acquisition Status	<b>—</b> ×
	XPS Spectral Acquire: 14 (sec)	
Acquiring Spectrum	Areas: 1/1 Cycles: 1/1 Regions: 1/1 Sweeps: 1/1	
	Stop Abort	

 The Region Scan spectra will appear in the Spectral Window following the sequence in Regions table.

Note:

- > The data files will be automatically saved into specified folder which can be opened in **MultiPak** program.
- > The **Sweep** times can be increased if the spectrum is noisy.
- > The Lower energy and Range can be adjusted to scan the interested regions only.
- > **Pass Energy** and **Step** size setup:
  - Good resolution: Pass Energy: 23.5 58.7 eV; Step Size: 0.125 0.25 eV/step; 20 ms Time Per Step
  - Superior resolution: Pass Energy 11.75 eV or lower. Step Size: 0.05 eV/step or lower; 20 ms Time Per Step
- > Sweep & Cycle suggestions:
  - **Sweep** only to individually created elements or regions
  - Cycle to all created regions



- 9) Add Q (Add to Queue mode) if interested elements are different on different samples:
  - a) Make sure a complete list of elements has been set up in the Regions window,
  - b) Go back to Sample window, check ONLY intended sample positions on the list,
  - c) Go to **XPS** window, **select ONLY** interested elements on intended sample positions,

d) Hit Add Q button in Spectrum window to add selected queue to the Add Q window below:

Automation						
		Queue		AutoTool	1	Errors/Warnings
Setting						
USER-1		-				
Load	Save Delete	🖒 File				
Jobs						4. 
Stort )		A V X				
Active Job		Summary				
ACQUIRE	SPECTRUM-1	1, 2, 3    SPECTRAL	_HP    C\/Datatiles\Yiren\201705074.jSx=SM7    LSx=5	Sm7    102    LiSx-Sm7    E-Neut    E-Neut    FNeut    FNeut	XPS    Z-Align    Standard    Spec	chum: FXS, 100u100W20KV_HP, Su1s, C1s, N1s, O1s, Fe2p3    SPECTRAL_HP
ACQUIRE	SPECTRUM-1	4.5.6    SPECTRAL	_HP    C\Detafiles\Yiren\20170507-LiSx-SM7    LiSx-5	5m7    102    LiSx-Sm7    E-Neut    E-Neut    HNeut    HNeut	XPS    Z-Align    Standard    Spec	ctrum: FXS. 100u100W20KV_HP. Su1s. C1s. N1s. O1s. Fe2p3. S2p. Li1s    SPECTRAL_HP
The P						
						Close

- e) **Minimize** above window, go back to **Sample** window and repeat **Step b**) **d**) until all sample positions are selected;
- f) Maximize the Add Q window and hit \_\_\_\_\_\_\_ to start spectral scan.

#### 9 Closing XPS Measurement

- 1) Checklist before sample extraction:
  - a) Go to System → Transfer Sample window, if the V3 valve is in green [1], indicating the Intro Chamber is in good vacuum, then skip Step 2) below;
  - b) Else If **V3 valve** is in red **Continue Step 2**) below
- 2) Click button on the Transfer Sample window, wait until the Intro pressure reaches below 4.0E-004 Pa on Cold Cathode gauge.

#### Warning:

> Sample transfer at high Intro Chamber pressure will introduce serious contaminations to Electron Energy Analyzer, X-ray, UV sources and sample stages.

Sample Transfer		
Create Sample	Sar	
a Create Sample		
Transfer Sample	ans	
	fer	
🗣 Intro 🦻 Extract		
Advanced Control	0	
Properties	amera	

- 3) Wait until the Intro Chamber pressure reaches below 4.0E-004 Pa and then click to start Sample Extraction
- 4) Wait until the following window appears:

Task Infor	mation	×				
•	Please move transfer arm to transfer position; Select [OK] only after arm is at the transfer position.					
	OK Cancel					

**XPS** 

- 5) Follow the command in above window to move the transfer arm forward and MAKE SURE the magnet TOUCHES the stopper ring and the stopper ring on the transfer arm. Warnings:
  - a) User should slow down when approaching transfer position. The sample holder should be SMOOTHLY inserted into the sample stage in Main Chamber.
     CONTACT lab manager immediately if strong force felt at this step,
  - b) **Slight adjustment** maybe needed to insert sample holder into the stage forks. The user should **CONTACT** lab manager for help,
  - c) **NEVER force** the sample into sample stage. Expensive parts inside will be **damaged**.



6) Leave the transfer arm at the transfer position; go back to the computer and click OK on the popup window

#### Warning:

- a) **NEVER** click **OK** on the window before moving transfer arm forward. Or **serious mechanical damage** to both stage and sample holder will occur. User account will be **suspended** and **repair cost** will be charged on PI's account.
- 7) Wait the following **window** to appear. **DO NOT** click **OK**:

Task Infor	mation			<b>—</b>
•	Please	retract transfer arm.	)	
		ОК	Cancel	

#### Warning:

- a) Failed to follow above step will lead to serious part damage to both sample stage and sample holder. User account will be suspended and repair cost will be charged on PI's account.
- Follows the command in above window to fully retract the transfer arm back to the Intro Chamber Warning:

- a) Retract the transfer arm **VERY SLOWLY** and watch the sample holder through **Main Chamber** view port. The sample holder should **STAY** on the transfer arm during extraction.
- 9) Go back to the computer and click OK on above window
- 10) **Wait until** the stage is driven to the center.

👰 AutoTool: INTRO PLATEN	
Driving Stage to Center	
💷 Stop	

11) **Turn OFF** the chamber light.



- 12) If your samples can be discarded, then Skip step 13) 15) and leave your samples inside Intro Chamber. The next user should clear your samples on the holder. Otherwise continue to steps below to retrieve your samples from Intro Chamber.
- 13) Click in Sample Transfer window below to vent the Intro Chamber

Sample Transfer	Sar	
😂 Create Sample		
Transfer Sample	ransf	
	er	
🗣 Intro 🍃 Extract		
Advanced Control	Ca	
Properties	nera	

Note: the user must wear gloves at hold the glass cover during venting

14) Wear gloves, wait until the Intro Chamber is vented, remove the sample and put the Viton cover back.

#### Warning:

- a) User **CAN NOT** touch the sample loading port with exposed skins
- b) **DO NOT** touch the camera atop the loading port

#### 15) Pump the Intro Chamber back to vacuum:

Warning: **DO NOT leave the Intro Chamber in air**, violation to this step will lead to **user account suspension!** 

- a) Click with button on the **Transfer Sample** window and go back to Intro Chamber quickly to **hold and press the Viton cover against the flange during Intro Chamber pumping**!
- b) Watch the Cold Cathode gauge reads 4.0E-004 Pa Warning: DO NOT logoff FOM if the pressure fails to reach 4.0E-004 Pa in a short time ~ 5- 10 minutes. It may indicate a chamber leak. Report to lab manager before leave.



- 16) Leave SmartSoft and Watcher programs ON.
- 17) Back up your data either through internet (Yale Box Sync) or using Core USB drive. Warning:
  - > personal USB drive is prohibited on instrument computers.

#### 18) Logoff FOM program

a) Click the *icon* at the task bar below to activate the **FOM** program, and hit **Logoff** button in the program.

**Note**: you may need to click the **EVE** twice to activate the **FOM** program



- b) Clear the bench and put tools back into the box and then check the message box in FOM window
- c) Hit Logoff button to activate FOM Screen Locker
- 19) Sign out on the logbook and report any problems on instrument.
- 20) **Remove** sample from the holder and **clean** it with clean wipes and **IPA**.
- 21) **Store** the sample holder, tongs and other tools in the tool box.

#### 10 Some Analysis Concepts

- > High X-ray Power → High sensitivity but poor spatial resolution (beam size is bad)
- > Low X-ray Power → Low sensitivity but good spatial resolution (beam size is good)
- > High Pass energy → High sensitivity but poor energy resolution (peak is FAT)
- > Low Pass energy →Low sensitivity but good energy resolution (peak is THIN)
- > **Big Step size** → Acquire time is short but peak shape (resolution) is bad
- > Small Step size → Acquire time is long but peak shape (resolution) is good
- > High sensitivity **>** Signal-to-Noise is better so total acquire time can be shorter
- > Low sensitivity -> Signal-to-Noise is worst so total acquire time needs to be longer
- > Sensitivity = Signal Intensity or counts

#### 11 Chamber Leaking Emergency Operation Procedure

#### 1) Intro Chamber leaking:

This could happen during **Intro Chamber** pumping after sample loading or sample removal.

- > The Intro Chamber pressure may sticks to ~ low E+001 Pa longer than ~ 15 minutes if the chamber is empty or has very dry samples inside, and turbo pump fails to start;
- > Or after turbo pumping starts, it takes more than **60 minutes** to reach **4.0E-004 Pa**.

#### To retrieve good vacuum in Intro Chamber:

- a) While the Intro Chamber is still being pumped, press and slight turn the Viton cover, and check if the pressure improves quickly, if NOT
- b) Vent the intro chamber through SmartSoft program. Take the cover off and check inner side of Viton O-ring for any dents, particles; clean with Kimwipes and isopropanol. Put the cover back, make sure the cover is placed properly and start pumping. Hold the cover firmly into the groves on the port during initial pumping. If the pressure is still not improved quickly, contact Core manager immediately.

#### 2) Main Chamber leaking

The Main Chamber could leak if the V1 valve is not closed properly due to either program failures or V1 valve damage.

- > To check if the **Main Chamber** is leaking:
  - > Make sure the **V1** valve is closed (in **red** border).
  - If the Main Chamber pressure drops rapidly from low E-007 or high E-008 Pa to E-006 ~ E-003 Pa when the Intro Chamber is vented for sample loading, indicating a series leak in the Main Chamber, a serious leak exists through V1 valve from Intro Chamber.
- **3)** Report the leak to Core manager immediately